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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/520,923	01/12/2005	Kazuya Kamitake	50395-305	4825	
20277 MCDERMOT	7590 04/11/2007 Γ WILL & EMERY LLP	EXAMINER			
600 13TH STREET, N.W.			WILLIAMS, ALEXANDER O		
WASHINGTON, DC 20005-3096			ART UNIT	PAPER NUMBER	
			2826		
SHORTENED STATUTOR	RY PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE		
3 MC	ONTHS	04/11/2007	PAPER		

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

		Application No.	Applicant(s)				
Office Action Summary		10/520,923	KAMITAKE ET AL.				
		Examiner	Art Unit				
		Alexander O. Williams	2826				
Period f	The MAILING DATE of this communication or Reply	n appears on the cover sheet w	I I	;			
A SH WHI - Extrafte - If N - Fail Any	HORTENED STATUTORY PERIOD FOR RICHEVER IS LONGER, FROM THE MAILIN ensions of time may be available under the provisions of 37 Cfr SIX (6) MONTHS from the mailing date of this communicatio O period for reply is specified above, the maximum statutory pure to reply within the set or extended period for reply will, by streply received by the Office later than three months after the med patent term adjustment. See 37 CFR 1.704(b).	G DATE OF THIS COMMUNI FR 1.136(a). In no event, however, may a n. eriod will apply and will expire SIX (6) MON statute, cause the application to become Al	CATION. reply be timely filed ITHS from the mailing date of this communic BANDONED (35 U.S.C. § 133).				
Status		•					
1) 🛛	Responsive to communication(s) filed on j	12 January 2005					
2a)		This action is non-final.					
3)□	·-		ers, prosecution as to the meri	its is			
,	closed in accordance with the practice und						
Disposi	tion of Claims		, ,	. •			
·	Claim(s) 12-32 is/are pending in the applic	eation					
٠,ڪ	4a) Of the above claim(s) is/are withdrawn from consideration.						
5)□	Claim(s) is/are allowed.	iaiami nom consideration.	•				
	Claim(s) <u>12-32</u> is/are rejected.						
7)	Claim(s) is/are objected to.						
8)		nd/or election requirement					
. —	tion Papers						
· ·	•						
	The description is objected to by the Example 1.		= .				
10)	The drawing(s) filed on is/are: a)						
	Applicant may not request that any objection to						
44	Replacement drawing sheet(s) including the co						
11)	The oath or declaration is objected to by the	e Examiner. Note the attached	d Office Action or form PTO-15	2.			
Priority	under 35 U.S.C. § 119						
	Acknowledgment is made of a claim for for ☐ All b)☐ Some * c)☐ None of:	eign priority under 35 U.S.C. §	119(a)-(d) or (f).				
	1. Certified copies of the priority documents have been received.						
	2. Certified copies of the priority documents have been received in Application No						
	3. Copies of the certified copies of the	priority documents have been	received in this National Stage	Э			
	application from the International Bu	ıreau (PCT Rule 17.2(a)).					
*	See the attached detailed Office action for a	a list of the certified copies not	received.				
Attachmei	nt(s)						
	ce of References Cited (PTO-892)	4) Interview S	Summary (PTO-413)				
	ce of Draftsperson's Patent Drawing Review (PTO-948 mation Disclosure Statement(s) (PTO/SB/08)		s)/Mail Date nformal Patent Application				
	er No(s)/Maif Date	6) Other:					
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Serial Number: 10/520923 Attorney's Docket #: 50395-305

Filing Date: 1/12/2005; claimed foreign priority to 7/17/2002 & 4/2/2003

Applicant: Kamitake et al.

Examiner: Alexander Williams

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This application is a 371 of PCT/JP03/08624 filed 7/7/2003.

Applicant's Pre-Amendment filed 1/12/2005 has been acknowledged.

Claims 1-11 have been cancelled.

Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

The lengthy specification has not been checked to the extent necessary to determine the presence of all possible minor errors. Applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

The following is a quotation of the appropriate paragraphs of 35 U.S.C. § 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains.

Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(f) or (g) prior art under 35 U.S.C. 103(a).

Claims 12 to 32 are rejected under 35 U.S.C. § 102(b) as being anticipated by Mahulikar et al. (U.S. Patent # 5,608,267).

- 12. Mahulikar et al. (figures 1 to 5) specifically figure 2 show a member for a semiconductor device 12 comprising a base member 26' made of an alloy or composite mainly composed of Cu and W and/or Mo, wherein a coating layer 42 made of a hard carbon film is provided on at least a surface of the base member on which another member for the semiconductor device is bonded with a resin.
- 13. The member for a semiconductor device according to claim 12, Mahulikar et al. show wherein the alloy or composite mainly composed of Cu and W and/or Mo contains Cu of 5 to 40% by weight.

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- 14. Mahulikar et al. (figures 1 to 5) specifically figure 2 show a member for a semiconductor device 12 comprising a base member 26' made of an alloy or composite mainly composed of Al-SiC, wherein a coating layer 42 made of a hard carbon film is provided on at least a surface of the base member on which another member for the semiconductor device is bonded with a resin.
- 15. The member for a semiconductor device according to claim 14, Mahulikar et al. show wherein the alloy or composite mainly composed of Al--SiC contains SiC of 10 to 70% by weight.
- 16. Mahulikar et al. (figures 1 to 5) specifically figure 2 show a member for a semiconductor device 12 comprising a base member 26' made of an alloy or composite mainly composed of Si-SiC, wherein a coating-layer 42 made of a hard carbon film is provided on at least a surface of the base member on which another member for the semiconductor device is bonded with a resin.
- 17. The member for a semiconductor device according to claim 16, Mahulikar et al. show wherein the alloy or composite mainly composed of Si--SiC contains Si of 10 to 35% by weight.
- 18. The member for a semiconductor device according to claim 12, wherein the coating layer has a thickness of 0.1 to 10 .mu.m.

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- 19. The member for a semiconductor device according to claim 14, Mahulikar et al. show wherein the coating layer has a thickness of 0.1 to 10 .mu.m.
- 20. The member for a semiconductor device according to claim 16, Mahulikar et al. show wherein the coating layer has a thickness of 0.1 to 10 .mu.m.
- 21. The member for a semiconductor device according to claim 12, Mahulikar et al. show wherein the surface of the base member on which the coating layer is formed has a surface roughness of 0.1 to 20 .mu.m in Rmax.
- 22. The member for a semiconductor device according to claim 14, Mahulikar et al. show wherein the surface of the base member on which the coating layer is formed has a surface roughness of 0.1 to 20 .mu.m in Rmax.
- 23. The member for a semiconductor device according to claim 16, Mahulikar et al. show wherein the surface of the base member on which the coating layer is formed has a surface roughness of 0.1 to 20 .mu.m in Rmax.
- 24. The member for a semiconductor device according to claim 12, Mahulikar et al. show wherein pores in the surface of the base member on which the coating layer is formed have a depth of 100 .mu.m or less.
- 25. The member for a semiconductor device according to claim 14, Mahulikar et al. show wherein pores in the surface of the

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base member on which the coating layer is formed have a depth of 100 .mu.m or less.

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- 26. The member for a semiconductor device according to claim 16, Mahulikar et al. show wherein pores in the surface of the base member on which the coating layer is formed have a depth of 100 .mu.m or less.
- 27. The member for a semiconductor device according to claim 12, Mahulikar et al. show wherein a plating layer of Ni is provided between the coating layer and the surface of the base member on which the coating layer is formed.
- 28. The member for a semiconductor device according to claim 14, Mahulikar et al. show wherein a plating layer of Ni is provided between the coating layer and the surface of the base member on which the coating layer is formed.
- 29. The member for a semiconductor device according to claim 16, Mahulikar et al. show wherein a plating layer of Ni is provided between the coating layer and the surface of the base member on which the coating layer is formed.
- 30. Mahulikar et al. show show a semiconductor device employing the member for a semiconductor device according to claim 12.
- 31. Mahulikar et al. show a semiconductor device employing the member for a semiconductor device according to claim 14.

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32. Mahulikar et al. show a semiconductor device employing the member for a semiconductor device according to claim 16.

The following references are cited as of interest to this application, but not applied at this time.

Field of Search	Date
U.S. Class and subclass: 257/704,707,710,778,734,737,738,e23,111,e23,181,e23.1 91	4/2/07
Other Documentation: foreign patents and literature in 257/704,707,710,778,734,737,738,e23,111,e23,181,e23.1 91	4/2/07
Electronic data base(s): U.S. Patents EAST	4/2/07

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Alexander O. Williams whose telephone number is (571) 272 1924. The examiner can normally be reached on M-F 6:30AM-7:00PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Sue Purvis can be reached on (571) 272 1236. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

> Alexander O Williams **Primary Examiner** Art Unit 2826

AOW 4/2/07